

# Flux pinning properties on SmBCO superconducting films with high number density of BaHfO<sub>3</sub> nano-rods at lower measurement temperatures

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In recent years, many researchers consider to apply REBa<sub>2</sub>Cu<sub>3</sub>O<sub>y</sub> (REBCO: RE = rare earth) coated conductors to coiled applications in a broad range of temperatures and magnetic fields. Hence, the investigation of the flux pinning properties is important.

Recently, we succeeded in controlling the size and number density ( $n$ ) of BaMO<sub>3</sub> (BMO) nano-rods exactly. In this study, our purpose is to reveal flux pinning properties in SmBCO films with various  $n$  of BHO nano-rods at various temperatures from 20 to 90 K. The films were fabricated by pulsed laser deposition (PLD) method adopting our seed layer technique at a low substrate temperature. This seed layer technique was named as “low-temperature growth (LTG)” technique. Here, we controlled doping levels of BHO in the films by alternating target technique.

As a result, the BHO nano-rods in the BHO-doped films prepared by the LTG technique became small in the diameter and had high  $n$  and it was much higher than those in films fabricated by conventional PLD method in spite of the same amount of BHO. For example, the  $n$  within the 5.6 vol.% BHO-doped film reached 4780 / $\mu\text{m}^2$ , and the matching field ( $B_\Phi$ ) which was calculated from  $n$  was about 10 T.

All the films showed good superconducting properties such as high critical temperatures ( $> 90$  K) and critical current density ( $> 1.5$  MA/cm<sup>2</sup>, @ 77 K). We measured the flux pinning properties at a broad range of temperatures under magnetic fields of 0 – 18 T ( $B//c$ ). Irreversibility fields at 77 K were 10 T for the 1.6 vol.% BHO-doped film and 15.1 T for the 5.6 vol.% BHO-doped film, respectively. So, the 5.6 vol.% BHO-doped film exhibited higher performance. The maximum flux pinning force densities ( $F_p^{\text{MAX}}$ ) were 779, 157 and 14.2 GN/m<sup>3</sup> at 20, 60 and 77 K, respectively. At high measurement temperature from 80 to 85 K, two peaks were observed in the  $F_p$ - $B$  curves of the 5.6 vol.% BHO film. We considered that these peaks might result in the flux pinning due to the BHO nano-rods and natural defects. On the contrary, at low measurement temperatures from 20 to 77 K, we observed only a single peak in the  $F_p$ - $B$  curves. We will discuss flux pinning properties in other samples and compare with the 5.6 vol.% BHO film.

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